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nanoMark

# CERTIFICATE

Certificate No. 2025-004

This is to certify that the products listed below produced by

**Hocheng Corporation**

are in compliance with the requirements of nanoMark Product Certification System

- I. Company Name : **Hocheng Corporation**
- II. Company Certificate : **No.019**
- III. Address : **No. 405, Fude 1st Rd., Bade Dist.,  
Taoyuan County 334, Taiwan (R.O.C)**
- IV. Representative : **Chiu, Li-Chien**
- V. Approved product : **Anti-Smudge Sanitary Facilities**
- VI. Product name, model/specification, approved item number and efficacy:  
please refer to the Appendix
- VII. Date of Certificate Issuance : **Jan. 01, 2025**  
Date of Certificate Expiration : **Dec. 31, 2025**

**Taiwan Nanotechnology  
Industry Development Association**



Jan.01, 2025



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# Appendix

Certificate No. 2025-004

- I. Company Name : **Hocheng Corporation**
- II. Approved product : **Anti-Smudge Sanitary Facilities**
- III. Product name, model/specification, approved item number and efficacy:

Product name	Model / Specification	Approved item number	Efficacy	Product name	Model / Specification	Approved item number	Efficacy
One piece toilet	C160	00122	In compliance with the requirements of 「TN-008 Verification and Validation Standard on Anti-Smudgy Sanitary Facilities」: the following specifications are satisfied, (1)The water contact angle is higher than 100°. The residual ratio of contaminant is less than 1%. The residual ratio of dense-contaminant is less than 1%. (2)Durability (scrub resistance) test : The contact angle is higher than 100° after 2000 cycles of scrubbing, the residual ratio of contaminant is less than 1% and the residual ratio of dense contaminant is less than 5%.	Close-couple toilet	CS999	00152	In compliance with the requirements of 「TN-008 Verification and Validation Standard on Anti-Smudgy Sanitary Facilities」: the following specifications are satisfied, (1)The water contact angle is higher than 100°. The residual ratio of contaminant is less than 1%. The residual ratio of dense-contaminant is less than 1%. (2)Durability (scrub resistance) test : The contact angle is higher than 100° after 2000 cycles of scrubbing, the residual ratio of contaminant is less than 1% and the residual ratio of dense contaminant is less than 5%.
	AFC233	00123			CS4272P	00153	
	C239ST	00124			C4288NBPAdb	00154	
	C301ST	00125			CS4384Adb	00155	
	C333AdbST	00126			CS4386AAdb	00156	
	C335ST	00127			C4388Adb	00157	
	C660AdbST	00128			CS4389PAdb	00158	
	C800AdbMUST	00129			C4515	00159	
	C840AdbMUST	00130			C5516PUAdb	00160	
	C899AdbMUST	00131			C5517PUAdb	00161	
	C4283AdbST	00132			CS5518EAdb	00162	
	C4286AdbST	00133			U24	00163	
	C4289PAdbST	00134			U28	00164	
	C5519NAdbMUST	00135			U29	00165	
C6677	00136	U29N	00166				
Close-couple toilet	C41N	00137	(2)Durability (scrub resistance) test : The contact angle is higher than 100° after 2000 cycles of scrubbing, the residual ratio of contaminant is less than 1% and the residual ratio of dense contaminant is less than 5%.	Urinal	U289	00167	
	C106NAdb	00138			U333BAdb	00168	
	C108N	00139			U660Adb	00169	
	C109N	00140			U661	00170	
	C128Adb	00141			U800Adb	00171	
	CS130E	00142			U999	00172	
	CS140E	00143			U4485Adb	00173	
	C141N	00144			U4486Adb	00174	
	C142N	00145			L100	00175	
	C145N	00146			L101Adb	00176	
	C218	00147			L102Adb	00177	
	CS662Adb	00148			LF103Q	00178	
	CS662A	00149			L104SAdb	00179	
	CS802NAdb	00150			LF105	00180	
CS923Adb	00151	L107S	00181				
Wash Basin					L107S	00181	

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# Appendix

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- I. Company Name : **Hocheng Corporation**
- II. Approved product : **Anti-Smudge Sanitary Facilities**
- III. Product name, model/specification, approved item number and efficacy:

Product name	Model / Specification	Approved item number	Efficacy	Product name	Model / Specification	Approved item number	Efficacy
Wash Basin	L120S	00182	In compliance with the requirements of 「TN-008 Verification and Validation Standard on Anti-Smudgy Sanitary Facilities」: the following specifications are satisfied, (1)The water contact angle is higher than 100°. The residual ratio of contaminant is less than 1%. The residual ratio of dense-contaminant is less than 1%. (2)Durability (scrub resistance) test : The contact angle is higher than 100° after 2000 cycles of scrubbing, the residual ratio of contaminant is less than 1% and the residual ratio of dense contaminant is less than 5%.	Wash Basin	L4056	00212	In compliance with the requirements of 「TN-008 Verification and Validation Standard on Anti-Smudgy Sanitary Facilities」: the following specifications are satisfied, (1)The water contact angle is higher than 100°. The residual ratio of contaminant is less than 1%. The residual ratio of dense-contaminant is less than 1%. (2)Durability (scrub resistance) test : The contact angle is higher than 100° after 2000 cycles of scrubbing, the residual ratio of contaminant is less than 1% and the residual ratio of dense contaminant is less than 5%.
	LF131SAdbR	00183			L4080	00213	
	LC134TG	00184			L4112SR	00214	
	LF161SAdbR	00185			LF4112SR	00215	
	L186SAdb	00186			LF4113SR	00216	
	L201S	00187			L4122S	00217	
	L252S	00188			LF4140R	00218	
	LF257SAdbR	00189			LF4174S	00219	
	LF259SAdbR	00190			LF4182SAdbR	00220	
	LF320	00191			LF4185SAdbR	00221	
	L323S	00192			LF5513NSAdb	00222	
	L333SAdbR	00193			L6633SAdb	00223	
	L337N	00194			L7080	00224	
	L351	00195		Following blank			
	L351S	00196					
	LF358SR	00197					
	L363NS	00198					
	LF367SR	00199					
	LF800SAdbR	00200					
	LF802SAdbR	00201					
	L957S	00202					
	LF964S	00203					
	L970SAdb	00204					
L3038	00205						
L4001	00206						
L4002S	00207						
L4003S	00208						
L4006	00209						
L4010	00210						
L4011	00211						

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